# **RSC Advances**

# PAPER

Check for updates

Cite this: RSC Adv., 2017, 7, 47898

Received 26th September 2017 Accepted 9th October 2017

DOI: 10.1039/c7ra10639d

rsc.li/rsc-advances

# Introduction

Gallium oxide  $(Ga_2O_3)$  and nitride (GaN) are wide band-gap semiconductors with energy gaps of  $\sim$ 4.6 and  $\sim$ 3.4 eV, respectively.<sup>1,2</sup> Both have attracted considerable interest for potential applications in spintronic, electronic and optoelectronic devices due to their intrinsic properties.3-7 The morphologies of these materials show significant impacts on their properties, and, therefore, they have received extensive attention in past decades.8-10 Various morphologies of GaN nanocrystals, e.g. nanowires, nanorods, nanotubes, nanobelts and nanohollows, have been successfully constructed and applied as electronic or optoelectronic devices.11-16 For example, Fan et al. prepared GaN nanorods through a confined reaction by using Ga<sub>2</sub>O vapour and NH<sub>3</sub> gas in the presence of carbon nanotubes as templates.<sup>11</sup> Yang et al. developed a chemical vapour deposition route to synthesize single GaN nanowire on sapphire substrate and further explored its promising applications in lasers.14 Subsequently, they reported the epitaxial growth of single-crystal GaN nanotubes by adopting hexagonal ZnO nanowires as templates also through chemical vapour deposition.<sup>17</sup> Chou et al. prepared GaN nanobelts through Au-assisted nucleation and non-Au-assisted anisotropy vaporsolid growth on LiAlO<sub>2</sub> substrate.<sup>18</sup> In addition, other strategies, e.g. metalorganic vapor phase epitaxy19 and rapid thermal ammonolysis of complex gallium fluoride,<sup>20,21</sup> have been reported for the synthesis of GaN and doped GaN nanostructures.

47898 | RSC Adv., 2017, 7, 47898-47903

# A simple synthesis of $Ga_2O_3$ and GaN nanocrystals<sup>+</sup>

Erwei Huang,<sup>a</sup> Juxia Li,<sup>a</sup> Guangjun Wu,<sup>a</sup> Weili Dai, 回 <sup>a</sup> Naijia Guan<sup>ab</sup> and Landong Li<sup>®\*ab</sup>

The synthesis of gallium oxide and nitride nanocrystals is challenging. Herein, a forced hydrolysis route is developed to synthesize a-GaOOH and the morphology control of nanocrystals is realized by adjusting the ratios of ionic strength in the synthesis system. The as-prepared α-GaOOH nanorods can be transformed into  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> nanorods upon calcination and can be further transformed into GaN nanocrystal assemblies through nitridation at elevated temperatures, which provides a top-down strategy to gallium oxide and nitride nanocrystals. The synthesis results are investigated by means of X-ray diffraction (XRD), Raman spectroscopy, scanning electron microscopy (SEM) and transmission electron microscopy (TEM). The optical properties, *i.e.* ultra-violet visible absorption (UV-vis) and photoluminescence, of as-obtained  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> nanocrystals with different morphologies are examined and the morphology-property relationship is discussed.

> According to these reports, it can be seen that the synthesis of GaN nanostructures always involves expensive and/or poisonous reagents, templates or substrates, and complicated processes.18-23 It is known that the nitridation of Ga<sub>2</sub>O<sub>3</sub> represents a most simple strategy to free-standing GaN material. Theoretically, the morphology of parent Ga<sub>2</sub>O<sub>3</sub> material can be preserved under controlled nitridation conditions, which provides a top-down morphology control strategy to GaN. It has been already reported that Ga2O3 nanorods can be synthesized via a thermal decomposition method using GaOOH nanorods.24 Moreover, GaN nanoparticles can be produced from Ga<sub>2</sub>O<sub>3</sub> nanoparticles under a flow of ammonia gas at elevated temperatures.25

> Inspired by these achievements, we herein report a so-called forced hydrolysis route to GaOOH nanorods, which can be transformed to Ga<sub>2</sub>O<sub>3</sub> nanorods through calcination and be further transformed to GaN nanocrystal assembles through nitridation. During the forced hydrolysis process, the hydroxyls are produced from urea decomposition<sup>26</sup> and morphology control of GaOOH is realized by adjusting the ratio of ionic strength in the synthesis system.

# Experimental

#### Synthesis of Ga<sub>2</sub>O<sub>3</sub> and GaN samples

All the chemical reagents were of analytical reagent grade and directly used without further purification. GaOOH was prepared via a forced hydrolysis route starting from solution containing Ga(NO<sub>3</sub>)<sub>3</sub> and NaNO<sub>3</sub> with different ionic strength ratios (see below for details).

Ionic strength (I) is calculated by formula of  $I \underline{\underline{\det}} \frac{1}{2} \sum_{D} m_B z_B^2$ , where  $m_B$  is the molality of an ion *B* in the solution and  $Z_B$  is its charge number (positive for cations and

<sup>&</sup>quot;School of Materials Science and Engineering, National Institute for Advanced Materials, Nankai University, Tianjin, 300350, P. R. China

<sup>&</sup>lt;sup>b</sup>Key Laboratory of Advanced Energy Materials Chemistry (Ministry of Education), Collaborative Innovation Center of Chemical Science and Engineering, Tianjin, 300071, P. R. China. E-mail: lild@nankai.edu.cn

*<sup>†</sup>* Electronic supplementary information (ESI) available. See DOI: 10.1039/c7ra10639d

negative for anions). The ratio of ionic strength (R) is defined as  $R = \frac{I_1}{I_2}$ , where  $I_1$  represents the ionic strength of Ga(NO<sub>3</sub>)<sub>3</sub> in the solution and I<sub>2</sub> represents the ionic strength of NaNO<sub>3</sub> in the solution.

In a typical synthesis, an appropriate amount of  $Ga(NO_3)_3 \cdot nH_2O$  and urea were dissolved into a small amount of deionized water (the molar ratio of  $Ga(NO_3)_3 \cdot nH_2O$  and urea being kept at 1:6) and heated to 90 °C. More deionized water was then added to reach a final molarity of urea is  $0.18 \text{ mol } \text{L}^{-1}$  $(Ga^{3+} of 0.03 mol L^{-1})$  and the temperature was kept at 90 °C for 9 h to initiate forced hydrolysis. The solid product was centrifuged, thoroughly washed, dried and defined as GaOOH ( $R = \infty$ ). The as-obtained GaOOH was calcined in the vacuum at 450 °C to derive Ga<sub>2</sub>O<sub>3</sub>, which was further nitridized in NH<sub>3</sub> flow  $(100 \text{ mL min}^{-1})$  at 950 °C for 6 h to derive GaN. With the addition of NaNO<sub>3</sub> into  $Ga(NO_3)_3 \cdot nH_2O$  solution at different ionic strength ratios, GaOOH products (R = 3, 2, 1, 0.5, 0.3 or 0.2), were obtained, which could also be transformed to Ga2O3 and GaN samples (R = 3, 2, 1, 0.5, 0.3 or 0.2) via identical procedures.

For reference, commercial Ga<sub>2</sub>O<sub>3</sub> (defined as Raw) was nitridized at 950 °C for 6 h to derive GaN.

#### Characterization of Ga<sub>2</sub>O<sub>3</sub> and GaN samples

The X-ray diffraction (XRD) patterns of samples were acquired on a Rigaku Smart Lab 3 kW powder diffractometer with Cu Ka radiation ( $\lambda = 0.1542$  nm) at a scanning rate of 6° min<sup>-1</sup>.

The specific surface areas of samples were determined through N<sub>2</sub> physisorption at 77 K on a Quantachrome iQ-MP gas adsorption analyzer.

Scanning electron microscopy (SEM) images of Ga2O3 and GaN samples were obtained on a JSM-7500F electron microscope.

Transmission electron microscopy (TEM) and highresolution transmission electron microscopy (HRTEM) images of Ga<sub>2</sub>O<sub>3</sub> and GaN samples were obtained on a FEI Tecnai G<sup>2</sup> F20 electron microscope at 200 kV. Alcohol suspensions containing the Ga<sub>2</sub>O<sub>3</sub> or GaN were dropped onto a carbon-coated copper grid, followed by evaporation at ambient temperature.

The Raman spectra of Ga2O3 and GaN were recorded on a Renishaw InVia Raman spectrometer with the green line of an Ar-ion laser (514.53 nm) in micro-Raman configuration.

Diffuse reflectance ultra-violet visible absorption (UV-vis) spectra of Ga2O3 and GaN samples were performed on a Varian Cary 300 UV/vis spectrophotometer.

Photoluminescence spectra of Ga<sub>2</sub>O<sub>3</sub> and GaN samples were acquired on a Spex FL201 fluorescence spectrophotometer. Selfsupporting wafers of samples (ca. 100 mg) were excited by 270 nm laser and the spectra were recorded in vacuum at ambient temperature.

### Results and discussion

The XRD patterns of GaOOH, Ga2O3 and GaN samples prepared at R = 1 are shown in Fig. 1. It can be seen that pure orthorhombic phase α-GaOOH is obtained from forced hydrolysis (JCPDS no. 06-0180; a = 4.58 Å, b = 9.80 Å, c = 2.97 Å). GaOOH can be

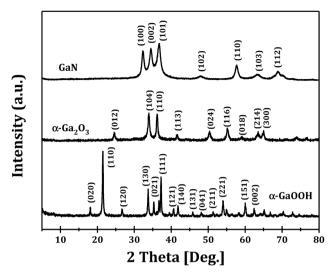


Fig. 1 XRD patterns of GaOOH, Ga<sub>2</sub>O<sub>3</sub> and GaN prepared at R = 1.

transformed to pure hexagonal phase  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> (JCPDS no. 06-0503; a = b = 4.98 Å, c = 13.43 Å) upon calcination at 450 °C and Ga<sub>2</sub>O<sub>3</sub> can be transformed to pure hexagonal phase GaN (JCPDS no. 50-0792; a = b = 3.19 Å, c = 5.19 Å) upon nitridation at 950 °C. These results clearly demonstrate the feasibility of Ga2O3 and GaN synthesis through a so-called top-down strategy.

Fig. 2 shows the XRD patterns of Ga<sub>2</sub>O<sub>3</sub> samples synthesized via forced hydrolysis at different R values and followed by calcination. All the samples exhibit similar diffraction peaks of  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> (JCPDS no. 06-0503), a monoclinic system and C2/m space group with a = b = 4.98 Å and c = 13.43 Å as its cell parameters.27 No diffraction peaks corresponding to impurity phases can be observed in all cases. We notice that, however, the intensities of diffraction peaks of Ga<sub>2</sub>O<sub>3</sub> samples synthesized at different R values are different, indicating that different morphologies and/or crystallinities were obtained for these  $Ga_2O_3$  samples. With increasing R value from 0.2 to 1, the

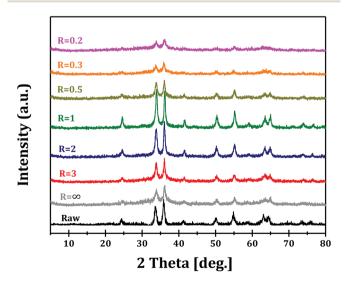
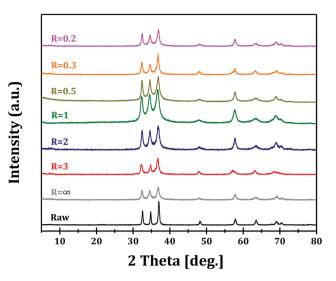


Fig. 2 XRD patterns of Ga<sub>2</sub>O<sub>3</sub> synthesized at different *R* values and Raw Ga<sub>2</sub>O<sub>3</sub>.



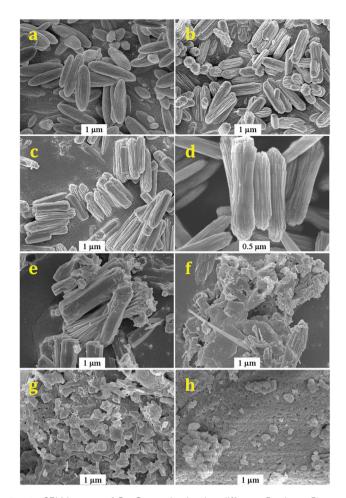
**Fig. 3** XRD patterns of GaN from the nitridation of  $Ga_2O_3$  synthesized at different *R* values and Raw  $Ga_2O_3$ .

relative crystallinity increases distinctly, while the relative crystallinity decreases with further increase in R value. That is,  $Ga_2O_3$  with highest crystallinity can be obtained with optimized ionic strength ratio of 1 during forced hydrolysis.

Raman spectroscopy is further employed to determine the structure of as-prepared  $Ga_2O_3$  samples. As shown in Fig. S1,<sup>†</sup> Raman bands at 410, 560 and 700–710 cm<sup>-1</sup> are observed in the 300–1000 cm<sup>-1</sup> region, corresponding to the E<sub>g</sub>, A<sub>1g</sub> and E<sub>g</sub> modes of  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub>, respectively.<sup>1,28</sup> The Raman bands broadening and the noticeable shifts of bands at 700–710 cm<sup>-1</sup> are due to the presence of surface defects on the samples.

The XRD patterns of GaN samples from the nitridation of different Ga<sub>2</sub>O<sub>3</sub> samples are shown in Fig. 3. Pure GaN phase of wurtzite structure and  $P6_3mc$  space group with a = b = 3.189 Å and c = 5.185 Å as its cell parameters is obtained in all cases.<sup>27</sup> We also notice the different intensities of diffraction peaks, similar to the trend observed for Ga<sub>2</sub>O<sub>3</sub> samples. It can be proposed that the morphologies and crystallinities of Ga<sub>2</sub>O<sub>3</sub> samples are preserved, at least partially preserved, through nitridation at elevated temperature of 950 °C. Raman spectra of GaN samples are presented in Fig. S2<sup>†</sup> and a series of Raman bands can be observed in the 300–1000 cm<sup>-1</sup> region. The band at 420 cm<sup>-1</sup> is related to the N-rich structure of GaN,<sup>29</sup> while the shifts of other Raman bands, *e.g.* at 515, 595 and 695 cm<sup>-1</sup>, compared with standard hexagonal GaN, should be related to the formation of abundant defects on the surface.<sup>20</sup>

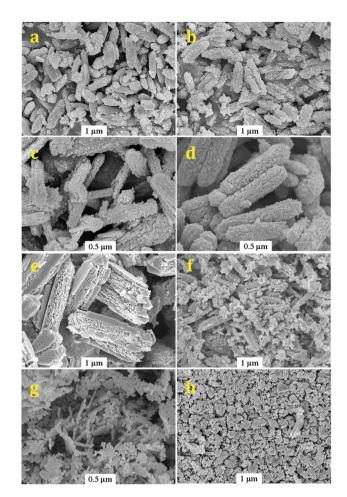
The SEM images of Ga<sub>2</sub>O<sub>3</sub> samples synthesized by forced hydrolysis at different *R* values are shown in Fig. 4. It is very clear that different morphologies are obtained at different ratios of ionic strength during forced hydrolysis, *i.e. R* values. At  $R = \infty$ , Ga<sub>2</sub>O<sub>3</sub> crystals appear as spindle-like nanorods with two narrow sides and a wide center (Fig. 4a). At R = 3 and 2, Ga<sub>2</sub>O<sub>3</sub> crystals appear as nanorods with the same broad sides and center (Fig. 4b and c). With decreasing *R* value to 1, Ga<sub>2</sub>O<sub>3</sub> crystals transform to dumbbell-shaped nanorods with two wide sides and narrow center (Fig. 4d). Further decrease in the ratio



**Fig. 4** SEM images of  $Ga_2O_3$  synthesized at different *R* values:  $R = \infty$  (a); R = 3 (b); R = 2 (c); R = 1 (d); R = 0.5 (e); R = 0.3 (f); R = 0.2 (g) and Raw  $Ga_2O_3$  (h).

of ionic strength during forced hydrolysis (R = 0.5 and 0.3) results in the exfoliation of nanorods to nanoplates and strips and fragments (Fig. 4e and f). At R = 0.2, the Ga<sub>2</sub>O<sub>3</sub> crystals are totally broken up to fragments. According to the SEM images of Ga<sub>2</sub>O<sub>3</sub> samples synthesized at different *R* values, we can infer that the crystallinities of Ga<sub>2</sub>O<sub>3</sub> samples vary with *R* values. The highest crystallinity of Ga<sub>2</sub>O<sub>3</sub> sample is obtained at the *R* value of 1, in accordance with the results from XRD patterns (Fig. 2). The surface areas of Ga<sub>2</sub>O<sub>3</sub> samples synthesized at different *R* values are measured to be in the range of 30–50 m<sup>2</sup> g<sup>-1</sup>, distinctly higher than commercial Ga<sub>2</sub>O<sub>3</sub> (15 m<sup>2</sup> g<sup>-1</sup>).

Fig. 5 shows the SEM images of GaN samples obtained from the nitridation of  $Ga_2O_3$  samples. It is seen that the overall shape of GaN sample follows its  $Ga_2O_3$  precursor. However, after careful observation, we find that some tiny nanoparticles do exist on the external surface of GaN crystals. These observations indicate that nitridation starts from a local point of  $Ga_2O_3$  crystal. The surface areas of as-obtained GaN samples are measured to be 40–60 m<sup>2</sup> g<sup>-1</sup>, even higher than parent  $Ga_2O_3$ (30–50 m<sup>2</sup> g<sup>-1</sup>) due to the formation of tiny nanoparticles on the surface. To confirm the phase purity of as-obtained GaN samples, the energy-dispersive X-ray mapping analysis was



**Fig. 5** SEM images of GaN from the nitridation of Ga<sub>2</sub>O<sub>3</sub> synthesized at different *R* values:  $R = \infty$  (a); R = 3 (b); R = 2 (c); R = 1 (d); R = 0.5 (e); R = 0.3 (f); R = 0.2 (g) and Raw Ga<sub>2</sub>O<sub>3</sub> (h).

performed on representative GaN sample (R = 1). As shown in Fig. S3,† the homogeneous distribution of Ga and N species in selected GaN crystal grain is clearly observed (Ga/N = 0.86; Ga/N < 1 due to the presence of N-containing impurities), ruling out the formation of metallic Ga islands from nitridation at high temperature of 950 °C.

For a more clear view of the morphology changes during nitridation, TEM images of  $Ga_2O_3$  and GaN samples synthesized at R = 1 are shown in Fig. 6. A typical  $Ga_2O_3$  crystal assembly appears as a nanorod with length of 2 µm and diameter of 0.4 µm (Fig. 6a). In the HRTEM images (Fig. 6b and c), clear lattice fringes with interplanar spacing of 0.249 nm are observed, corresponding to the (110) planes of  $Ga_2O_3$  crystal. After nitridation, the overall shape of  $Ga_2O_3$  is well preserved (Fig. 6d), in accordance with SEM observations. It is also found that the GaN crystal assembly is composed of tiny nanoparticles with sizes of a few to a dozen nanometers. Accordingly, some nanoscale mesopores can be observed in GaN crystal assembly. HRTEM images (Fig. 6e and f) reveal the lattice fringes with interplanar spacing of 0.276 nm, corresponding to the (100) planes of GaN crystal.

On the basis of SEM (Fig. 4) and TEM observations (Fig. 6), we demonstrate that  $Ga_2O_3$  samples with different morphologies

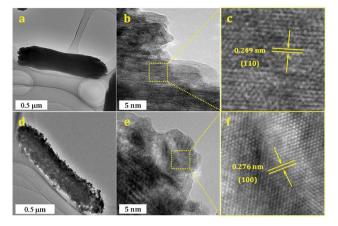


Fig. 6 TEM images (a, d), HRTEM images (b, e) and enlarged view of HRTEM images (c, f) of  $Ga_2O_3$  and GaN samples synthesized at R = 1.

can be prepared *via* controlling the ratio of ironic strength during forced hydrolysis. With decreasing *R* value, the morphology of  $Ga_2O_3$  crystals gradually transforms from spindle-like to dumbbell-shaped nanorods and then to exfoliated fragments, which gives us a hint on the formation process of  $Ga_2O_3$  sample.

A schematic diagram of morphology-controlled synthesis of  $Ga_2O_3$  *via* forced hydrolysis route is summarized in Fig. 7. In the first step, different ratios of  $Ga(NO_3)_3 \cdot nH_2O$ , NaNO<sub>3</sub> and urea are mixed in deionized water and heated at 90 °C to form unstable  $Ga(OH)_3$  transition state. Then, the unstable  $Ga(OH)_3$  transition state crystallizes to different morphologies of  $\alpha$ -GaOOH at 90 °C with the presence of different concentrations of sodium ions as structure-directing and mineralizing agents. In the final step, GaOOH is transformed to  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> through calcination in vacuum, with its morphology well preserved. Besides, the as-obtained  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> can be transformed to GaN with overall morphology well preserved (Fig. 6).

The optical properties of as-obtained  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> samples with different morphologies are examined to explore the possible morphology-dependent effects. The UV-vis spectra of  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> synthesized at different *R* values are shown in Fig. 8. Commercial  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> sample (Raw) shows significant absorption in the ultraviolet region with edge up to ~290 nm, corresponding to the

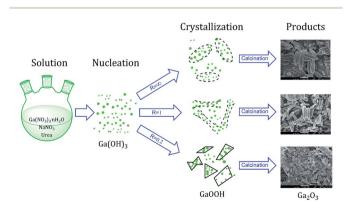


Fig. 7 Schematic diagram of morphology-controlled synthesis of  $Ga_2O_3$  via forced hydrolysis route.

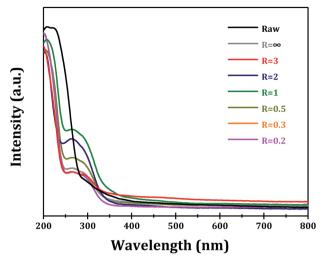


Fig. 8 UV-vis spectra of Ga<sub>2</sub>O<sub>3</sub> synthesized at different *R* values.

band gap of ~4.3 eV. While for  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> samples prepared *via* forced hydrolysis, two absorption peaks can be distinguished, *i.e.* intrinsic absorption with edge up to ~260 nm (4.8 eV) and subband absorption with edge up to ~360 nm (3.5 eV). The subband absorption should be related with the existence of abundant defect sites in  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub>, *e.g.* oxygen vacancies as proposed in other oxide semiconductors.<sup>30,31</sup> It is seen that the highest absorption with edge up to ~360 nm is obtained with  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> sample at *R* = 1, indicating its highest defect site concentration.

For GaN samples from the nitridation of  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> samples, significant absorption in the ultraviolet and visible region is observed (Fig. S4<sup>†</sup>). The band-edge energy cannot be distinguished due to the overlap by sub-band absorption as well as the serious light scattering effects caused by the formation of mesoporous structure (Fig. 5 and 6).

The photoluminescence properties of α-Ga<sub>2</sub>O<sub>3</sub> samples synthesized at different R values are examined. It is known that the photoluminescence emissions are originated from the radiative recombination of photo-generated electrons and holes on semiconductors. Two major photo-physical processes, i.e. direct band-band transition and indirect transition from trapping states, can give rise to photoluminescence signals. Under 270 nm ultraviolet light excitation, a broad photoluminescence signal from 350 to 700 nm (centered at 500 nm) is observed for commercial  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> sample (Fig. 9). While for  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> samples prepared via forced hydrolysis followed by calcination, two significant photoluminescence signals at 460 (blue photoluminescence) and 600 nm (orange photoluminescence) are observed. The blue photoluminescence signal should be originated from the recombination of photogenerated electrons on donors and holes on acceptors while the orange photoluminescence from the recombination on deep trapping states.32,33 Undoubtedly, all these two photoluminescence signals are associated with the defect sites in as-prepared α-Ga<sub>2</sub>O<sub>3</sub> samples, which distinguish them from commercial sample. In this context, the intensity of photoluminescence signals is determined by both the defect sites and the crystallinity of the sample.

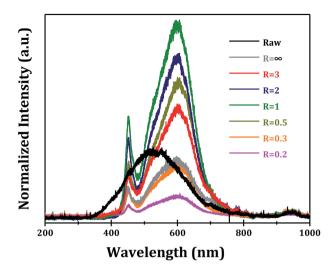


Fig. 9 Photoluminescence spectra of  $Ga_2O_3$  synthesized at different R values.

We find that the sequence of photoluminescence intensity (Fig. 9) correlates well with the optical absorption (Fig. 8), both of which indicate the morphology-dependent optical properties of  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> samples. At R = 1, the highest photoluminescence intensity is obtained, several times higher than commercial  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> sample.

We also investigate the optical properties of GaN samples prepared from the nitridation of  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> samples and the results are shown in Fig. S5.† Significant photoluminescence signals at 380 and 450 nm are observed for all samples in the 350–480 nm region, and the highest photoluminescence intensity is obtained with GaN (R = 1). Besides, we cannot draw other convincing conclusions on the morphology-dependent effects due to the serious light scattering effects caused by the formation of mesoporous structure. Further researches on these issues are still in progress.

### Conclusions

In summary, we have successfully developed a forced hydrolysis route to α-GaOOH starting from inorganic gallium salt and urea as raw materials, and we have realized the morphology control by adjusting the ratios of ionic strength in the synthesis system, i.e.  $Ga^{3+}/Na^{+}$ . The as-prepared  $\alpha$ -GaOOH nanorods can be transformed to α-Ga<sub>2</sub>O<sub>3</sub> nanorods upon simple calcination with the morphology well preserved, and be further transformed to GaN nanocrystal assembles through nitridation. This process provides a top-down strategy to  $Ga_2O_3$  and GaN nanocrystals. Typically, the morphology of as-obtained α-Ga<sub>2</sub>O<sub>3</sub> crystals gradually transform from spindle-like to dumbbell-shaped nanorods and then to exfoliated fragments with decreasing ratios of ionic strength in the synthesis system. While for the GaN samples prepared from nitridation at elevated temperature, the overall shape of  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> precursor can be preserved and nanoscale mesopores originated from nanoparticles assembling are clearly observed.

The UV-vis absorption and photoluminescence properties of Ga<sub>2</sub>O<sub>3</sub> crystals with different morphologies are examined, and the

results clearly demonstrate the morphology-dependent effects. The methodology presented here may be extended to the synthesis and applications of other oxide and nitride semiconductors.

# Conflicts of interest

There are no conflicts to declare.

## Acknowledgements

This work is financially supported by the National High Technology Research and Development Program of China (2015AA033303) the National Natural Science Fund of China (21421001).

### Notes and references

- X. Wang, Q. Xu, M. Li, S. Shen, X. Wang, Y. Wang, Z. Feng,
   J. Shi, H. Han and C. Li, *Angew. Chem., Int. Ed.*, 2012, 51, 13089–13092.
- 2 K. Maeda, T. Takata, M. Hara, N. Saito, Y. Inoue, H. Kobayashi and K. Domen, *J. Am. Chem. Soc.*, 2005, **127**, 8286–8287.
- 3 T. Ohno, L. Bai, T. Hisatomi, K. Maeda and K. Domen, *J. Am. Chem. Soc.*, 2012, **134**, 8254–8259.
- 4 P. Parkinson, C. Dodson, J. J. Joyce, K. A. Bertness, N. A. Sanford, L. M. Herz and M. B. Johnston, *Nano Lett.*, 2012, **12**, 4600–4604.
- 5 T. Hashimoto, F. Wu, J. S. Speck and S. Nakamura, *Nat. Mater.*, 2007, **6**, 568–571.
- 6 J. Hejtmánek, K. Knížek, M. Maryško, Z. Jirák,
  D. Sedmidubský, Z. Sofer, V. Peřina, H. Hardtdegen and
  C. Buchal, *J. Appl. Phys.*, 2008, 103, 07D107.
- 7 Z. Sofer, D. Sedmidubský, J. Stejskal, J. Hejtmánek,
  M. Maryško, K. Jurek, M. Václavů, V. Havránek and
  A. Macková, *J. Cryst. Growth*, 2008, **310**, 5025–5031.
- 8 X. F. Wang, J. H. Tong, X. Chen, B. J. Zhao, Z. W. Ren, D. W. Li, X. J. Zhuo, J. Zhang, H. X. Yi, C. Liu, F. Fang and S. T. Li, *Chem. Commun.*, 2014, **50**, 682–684.
- 9 C. T. Huang, J. H. Song, W. F. Lee, Y. Ding, Z. Y. Gao, Y. Hao, L. J. Chen and Z. L. Wang, *J. Am. Chem. Soc.*, 2010, **132**, 4766– 4771.
- 10 R. Zou, Z. Zhang, Q. Liu, J. Hu, L. Sang, M. Liao and W. Zhang, Small, 2014, 10, 1848–1856.
- 11 W. Han, S. Fan, Q. Li and Y. Hu, *Science*, 1997, 277, 1287– 1289.
- 12 X. Sun and Y. Li, Angew. Chem., Int. Ed., 2004, 43, 3827-3831.

- 13 J. Wallys, J. Teubert, F. Furtmayr, D. M. Hofmann and M. Eickhoff, *Nano Lett.*, 2012, **12**, 6180–6186.
- 14 J. C. Johnson, H. J. Choi, K. P. Knutsen, R. D. Schaller, P. D. Yang and R. J. Saykally, *Nat. Mater.*, 2002, 1, 106–110.
- 15 Y. J. Hwang, C. H. Wu, C. Hahn, H. E. Jeong and P. D. Yang, *Nano Lett.*, 2012, **12**, 1678–1682.
- 16 P. Huang, H. Zong, J. J. Shi, M. Zhang, X. H. Jiang, H. X. Zhong, Y. M. Ding, Y. P. He, J. Lu and X. D. Hu, ACS Nano, 2015, 9, 9276–9283.
- 17 J. Goldberger, R. R. He, Y. F. Zhang, S. W. Lee, H. Q. Yan, H. J. Choi and P. D. Yang, *Nature*, 2003, 422, 599–602.
- 18 C. L. Chen, M. M. C. Chou, T. Yan, H. C. Huang, C. Y. J. Lu and C. H. Chen, *Chem. Commun.*, 2014, **50**, 5695–5698.
- Z. Sofer, D. Sedmidubský, Š. Huber, J. Hejtmánek,
   A. Macková and R. Fiala, *Int. J. Nanotechnol.*, 2012, 9, 809– 824.
- 20 Z. Sofer, D. Sedmidubský, Š. Huber, P. Šimek, F. Šaněk, O. Jankovský, E. Gregorová, R. Fiala, S. Matěějková and M. Mikulics, *J. Nanopart. Res.*, 2013, **15**, 1411.
- 21 P. Šimek, D. Sedmidubský, Š. Huber, K. Klímová, M. Maryško, M. Mikulics and Z. Sofer, *Mater. Chem. Phys.*, 2015, 164, 108–114.
- 22 X. Chen, J. Xu, R. M. Wang and D. Yu, *Adv. Mater.*, 2003, **15**, 419–421.
- 23 Y. Xie, Y. Qian, W. Wang, S. Zhang and Y. Zhang, *Science*, 1996, **272**, 1926–1927.
- 24 X. Liu, G. Qiu, Y. Zhao, N. Zhang and R. Yi, *J. Alloys Compd.*, 2007, **439**, 275–278.
- 25 T. Ogi, Y. Kaihatsu, F. Iskandar, E. Tanabe and K. Okuyama, *Adv. Powder Technol.*, 2009, **20**, 29–34.
- 26 W. H. R. Shaw and J. J. Bordeaux, *J. Am. Chem. Soc.*, 1955, 77, 4729–4733.
- 27 M. Muruganandham, R. Amutha, M. S. M. A. Wahed, B. Ahmmad, Y. Kuroda, R. P. S. Suri, J. J. Wu and M. E. T. Sillanpää, *J. Phys. Chem. C*, 2012, **116**, 44–53.
- 28 D. Machon, P. F. McMillan, B. Xu and J. Dong, *Phys. Rev. B*, 2006, 73, 094125.
- 29 J. Q. Ning, S. J. Xu, D. P. Yu, Y. Y. Shan and S. T. Le, *Appl. Phys. Lett.*, 2007, 91, 103117.
- 30 J. Yan, T. Wang, G. Wu, W. Dai, N. Guan, L. Li and J. Gong, *Adv. Mater.*, 2015, 27, 1580–1586.
- 31 L. Li, J. Yan, T. Wang, Z. J. Zhao, J. Zhang, J. Gong and N. Guan, *Nat. Commun.*, 2015, 6, 5881.
- 32 T. Harwig and F. Kellendonk, J. Solid State Chem., 1978, 24, 255–263.
- 33 L. Binet and D. Gourier, *J. Phys. Chem. Solids*, 1998, **59**, 1241–1249.